

# UNITED STATES PATENT AND TRADEMARK OFFICE

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APPLICATION NO. FILING DATE		LING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/832,978	(	04/12/2001	Hideo Kitagawa	35.C15293	9731
5514	7590	09/25/2002			
		LA HARPER &	EXAMINER		
30 ROCKEI NEW YORI			OLSEN, ALLAN W		
				ART UNIT	PAPER NUMBER
				1763	4
				DATE MAILED: 09/25/2002	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Applicati n N .	Applicant(s)					
	09/832,978	KITAGAWA ET AL.					
Office Action Summary	Examin r	Art Unit					
	Allan W. Olsen	1763					
The MAILING DATE of this communication appears on the c ver sheet with the correspondence address Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period w Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).  Status	36(a). In no event, however, may a reply be time within the statutory minimum of thirty (30) days fill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).					
1) Responsive to communication(s) filed on 12 A	pril 2001 .						
2a) This action is <b>FINAL</b> . 2b) ⊠ Thi	s action is non-final.	1					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213. isposition of Claims							
4) Claim(s) 1-20 is/are pending in the application.							
4a) Of the above claim(s) is/are withdraw							
5) Claim(s) is/are allowed.	WITHOUT CONSIDERATION.						
· <u> </u>		,					
6)⊠ Claim(s) <u>1-20</u> is/are rejected.							
7) Claim(s) is/are objected to.	. al-alian naminanan						
8) Claim(s) are subject to restriction and/or election requirement.  Application Papers							
9) The specification is objected to by the Examiner.							
10) The drawing(s) filed on is/are: a) □ accepted or b) □ objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
11) ☐ The proposed drawing correction filed on is: a) ☐ approved b) ☐ disapproved by the Examiner.							
If approved, corrected drawings are required in reply to this Office action.							
12) The oath or declaration is objected to by the Examiner.							
Priority under 35 U.S.C. §§ 119 and 120		•					
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).							
a)⊠ All b)⊡ Some * c)⊡ None of:							
1. Certified copies of the priority documents	s have been received.						
2. Certified copies of the priority documents	s have been received in Application	on No					
3. Copies of the certified copies of the priority documents have been received in this National Stage							
application from the International Bureau (PCT Rule 17.2(a)).  * See the attached detailed Office action for a list of the certified copies not received.							
14) ☐ Acknowledgment is made of a claim for domestic	priority under 35 U.S.C. § 119(e	e) (to a provisional application).					
a) ☐ The translation of the foreign language provisional application has been received. 15)☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.							
Attachment(s)							
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s) 2.	5) Notice of Informal F	(PTO-413) Paper No(s) Patent Application (PTO-152)					
S. Patent and Trademark Office PTO-326 (Rev. 04-01) Offic Act	tion Summary	Part of Paper No. 4					

Application/Control Number: 09/832,978

**Art Unit: 1763** 

#### **DETAILED ACTION**

## Specification

The disclosure is objected to because of the following informalities:

page 3, line 4 - "2" should be --3--;

page 8, lines 8-13 - this paragraph/sentence is not clear;

page 10, line 23 - After allowed patent application 09/082,006 issues the specification should refer to the patent number.

Appropriate correction is required.

### Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-4, 6-15 and 17-20 are rejected under 35 U.S.C. 103(a) as being unpatentable over U. S. Patent 6,037,255 issued to Hussein et al. (hereinafter, Hussein).

Hussein teaches a method of patterning an organic dielectric layer (103). Hussein teaches applying a patterned photoresist to a hard mask layer (104) that overlies the organic dielectric. After exposing a portion of the organic layer, Hussein teaches that the exposed portion is removed by plasma etching, wherein the plasma gas contains N<sub>2</sub> and H<sub>2</sub>. Hussein teaches the organic layer is a polymer. Hussein teaches the use of low k dielectric polymers such as FLARE<sup>TM</sup> and polyarylethers (column 2, line 57 - column 3, line 6). Hussein teaches using a hard mask material that comprises titanium (column lines 37-38 and column 2, lines 43-49). Hussein also discloses the utility of tantalum in the barrier/mask layers (column 3, line 63).

Application/Control Number: 09/832,978

Art Unit: 1763

Claims 5 and 16 are rejected under 35 U.S.C. 103(a) as b ing unpat ntabl over Hussein as applied t claims 1 and 11 abov and further in view of Suzuki t al. in EP 0880164 (hereinafter, Suzuki).

Hussein does not teach using a surface-wave interfered plasma.

Suzuki teaches using a surface-wave interfered plasma.

It would have been obvious to one skilled in the art to use a surface-wave interfered plasma because Suzuki teaches that this provides a uniform high density plasma over a large area. Additionally a higher quality plasma processing can be accomplished at lower temperatures over a wider pressure range (column 4).

#### **Conclusion**

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Allan Olsen whose telephone number is 703-306-9075. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Greg Mills, can be reached on 703-308-1633.

The examiner's Right-Fax (direct to desktop) phone number is 703-872-9684.

Alternatively, the general fax numbers for TC1700 are 703-872-9310 (non-after finals) and 703-872-9311(after-final).

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the Group receptionist whose telephone number is (703) 308-0661.

Allan Olsen, Ph.D. September 15, 2002

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